

REMARKS

Applicants appreciate the indication that claims 3, 9 and 16 would be allowable if rewritten in independent form, including all of the limitations of the base claim and any intervening claims. This has now been done for claim 3 (after correcting a typographical error) and the claims originally dependent upon claim 1 have been amended to depend from claim 3 instead. Claim 1 has been cancelled. Therefore, claims 2-17 are believed to be allowable.

The limitation of original claim 3 has also been added to the remaining independent claims 18, 22, 24, 25, 27, 29 and 30. For this reason, the remaining claims 18-30 are also believed to be allowable.

Claims 2-30 are presently pending in the application. Allowance of all the presently standing claims is respectfully requested.

EXPRESS MAIL LABEL NO:

EV 259161388 US

Respectfully submitted,



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VERSION WITH MARKINGS TO SHOW CHANGES MADE

1. ~~(Cancelled) A nanometer scale apparatus, comprising:
an elongated structure with nanometer cross sectional dimensions; and
a device comprising components substantially on opposite sides of the elongated structure, said components applying an electric field across them to the elongated structure in a direction transverse to the elongated structure so that energy band structure of the elongated structure is altered.~~

2. (Amended) The apparatus of claim ~~13~~ 3, wherein said structure comprises a silicon or carbon material.

3. (Amended) A nanometer scale apparatus, comprising:
an elongated structure with nanometer cross-sectional dimensions; and
a device comprising components substantially on opposite sides of the elongated structure, said components applying an electric field across them to the elongated structure in a direction transverse to the elongated structure so that energy band structure of the elongated structure is altered~~The apparatus of claim 1, wherein said electric field is not less than about 1 MeV/m.~~

4. (Amended) ~~The apparatus of claim 1~~ 3, wherein said components comprise at least one nanotube or nanowire.

5. (Amended) ~~The apparatus of claim 1~~ 3, wherein said components comprise at least one multiple wall nanotube.

6. (Amended) ~~The apparatus of claim 1~~ 3, wherein said components comprise two elongated nanotubes or nanowires oriented in directions transverse to the elongated structure and applying the electric field to a portion of the elongated structure at a location between and overlapping the two nanotubes or nanowires of the components, thereby forming a cross junction arrangement with the elongated structure.

7. (Amended) The apparatus of claim-4 3, further comprising a dielectric material between the components and the elongated structure.

8. (Amended) The apparatus of claim-4 3, wherein said structure comprises at least one multiple wall nanotube.

9. (Amended) The apparatus of claim-4 3, wherein said structure comprises at least one zigzag carbon nanotube.

10. (Amended) The apparatus of claim-4 3, wherein said electric field causes change in electrical conductance of the elongated structure by redistributing electrical charge on the elongated structure without changing net electrical charge on the elongated structure.

11. (Amended) The apparatus of claim-4 3, wherein said structure comprises at least one semiconducting nanotube or nanowire.

12. (Amended) The apparatus of claim-4 3, wherein said change in energy band structure also causes a change in electrical conductance of the elongated structure.

13. (Amended) The apparatus of claim-4 3, wherein said change in energy band structure also causes a shift in optical energy absorption wavelength characteristics by the elongated structure.

14. (Amended) The apparatus of claim-4 3, wherein said components applies the electric field to a section of the elongated structure, so that the change in energy band structure caused by the field also causes a quantum well to develop at or near the section of the elongated structure.

15. (Amended) The apparatus of claim 13, wherein said components apply electric field(s) to two or more sections of the elongated structure, wherein said sections are spaced apart from one another, so that the change in energy band structure caused by the field also causes a number of quantum wells to develop at or near the sections of the elongated structure.

16. The apparatus of claim 15, wherein said sections are spaced apart from one another by spacings selected such that the elongated structure reflects electromagnetic radiation of wavelengths that are functions of the spacings.

17. (Amended) The apparatus of claim 13, wherein said components apply the electric field to the elongated structure so that there is an electric field gradient across the elongated structure.

18. (Amended) A nanometer scale transistor apparatus, comprising:
an elongated structure with nanometer cross-sectional dimensions;
a device comprising components substantially on opposite sides of the elongated structure, said components applying an electric field across them to the elongated structure in a direction transverse to the elongated structure so that electrical conductance of the elongated structure is altered, wherein said electric field is not less than about 1 MV/m; and
a source and a drain electrically connected to the elongated structure.

19. The apparatus of claim 18, further comprising a dielectric material between the components and the elongated structure.

20. The apparatus of claim 18, wherein said components comprise two elongated nanotubes or nanowires oriented in directions transverse to the elongated structure and applying the electric field to a portion of the elongated structure at a location between and overlapping the two nanotubes or nanowires of the components, thereby forming a cross junction arrangement with the elongated structure.

21. The apparatus of claim 18, wherein said components comprise at least one multiple wall nanotube.

22. (Amended) A nanometer scale photodetector apparatus, comprising:
an elongated structure with nanometer cross-sectional dimensions;
a device comprising components substantially on opposite sides of the elongated structure, said components applying an electric field across them to the elongated structure in a direction transverse to the elongated structure to cause a shift in optical energy absorption wavelength characteristics by the elongated structure, wherein said electric field is not less than about 1 MV/m; and
two electrical terminals electrically connected to the elongated structure.

23. The apparatus of claim 22, said device further comprising a voltage source applying an electrical potential across said components, said source being tunable to select wavelength of radiation that is absorbed by the elongated structure.

24. (Amended) A nanometer scale polaron apparatus, comprising:
an elongated structure with nanometer cross-sectional dimensions;
a device comprising components substantially on opposite sides of the elongated structure, said components applying an electric field across them to a portion of the elongated structure in a direction transverse to the elongated structure, wherein said electric field is not less than about 1 MV/m; and
a source providing radiation to the portion to cause a change in length of the elongated structure.

25. (Amended) A nanometer scale radiation reflector apparatus, comprising:
an elongated structure with nanometer cross-sectional dimensions; and
a device comprising components substantially on opposite sides of the elongated structure, said components applying an electric field across them to a portion of the elongated structure in a direction transverse to the elongated structure to cause a plurality

of quantum wells along a length of the elongated structure, said wells being spaced apart by spacings selected to reflect radiation of predetermined wavelengths, wherein said electric field is not less than about 1 MV/m.

26. The apparatus of claim 25, said device further comprising a plurality of pairs of elongated electrodes, each pair located substantially on opposite sides of the elongated structure and oriented in directions transverse to the elongated structure, the spacing between each pair of electrodes selected to reflect radiation of predetermined wavelengths.

27. (Amended) A nanometer scale laser apparatus, comprising:
a optical gain region;
one or more elongated structure(s) on one or more than one side of the region, each of said structure(s) having nanometer cross-sectional dimensions;
a device comprising components substantially on opposite sides of each of the one or more structure(s), said components applying an electric field across them to a portion of each of the one or more structure(s) in a direction transverse to such structure to cause one or more quantum wells in such structure, wherein said electric field is not less than about 1 MV/m; and
an instrument causing electrons and holes to be injected into the region.

28. The apparatus of claim 27, said components comprising a pair of elongated electrodes located substantially on opposite sides of the elongated structure and oriented in directions substantially along a length of the elongated structure.

29. (Amended) A nanometer scale quantum computing apparatus, comprising:
an elongated structure with nanometer cross-sectional dimensions; and
a device comprising components substantially on opposite sides of the elongated structure, said components applying an electric field across them to a portion of the elongated structure in a direction transverse to the elongated structure to cause a plurality

of quantum wells adjacent to one another along a length of the elongated structure, said wells trapping ions, wherein said electric field is not less than about 1 MV/m,

a source supplying radiation to at least one of the wells; and

an ion tip in the vicinity of the at least one of the wells, causing a change in state of ions in such well when radiation is supplied to such well, and detecting the state of ions in such well when radiation is not supplied to such well.

30. (Amended) A nanometer scale apparatus, comprising:

an elongated structure with nanometer cross-sectional dimensions; and

a device that causes an electrical potential gradient to develop around a perimeter of the elongated structure so that energy band structure of the elongated structure is altered, wherein the electrical potential gradient causes an electric field of not less than about 1 MV/m across the structure.